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Contents

Shanshan Wang, Qiong Wei, Tao Zhu, Jianyong Huang,
Min Yu, Yinlin Sha, Chunyang Xiong and Jing Fang
**CD4+ T Cell Counting by Impedance Measurement on a
Chip with Fluidic Electrodes — 311**

Luke Rajah, Duncan A. White and Tuomas P. J. Knowles
**Highly Non-linear Microfluidic Resistor Elements for Flow
Rate-dependent Addressing of Microchannels — 319**

Wei Wang, Tao Luo, Xiao-Jie Ju, Rui Xie, Li Liu and
Liang-Yin Chu
**Microfluidic Preparation of Multicompartment
Microcapsules for Isolated Co-encapsulation and
Controlled Release of Diverse Components — 325**

Jaesool Shim, Prashanta Dutta
**Joule Heating Effect in Constant Voltage Mode
Isotachophoresis in a Microchannel — 333**

Xing Yang, Jiang Li and Haosheng Chen
**Cavitation in Negative-pressure Microcapillary Devices
with Tapered Constrictions: Experiment and Numerical
Simulation — 345**

Alban Sauret and Ho Cheung Shum
Beating the Jetting Regime — 351

